

CuNiSi

EN 2024 06

Comparable standards: Aurubis designations:

UNS C19005 • PNA 326

Description

PNA 326 is an optimized version of CuNi1.5Si, which is a precipitation-hardened copper alloy. It combines medium electrical conductivity (min. 47% IACS) with high strength and good relaxation behaviour. This is achieved by the application of a special process consisting of cold working and heat treatment. It also has excellent spring properties and good corrosion resistance.

Composition

Cu	Ni	Si	Zn	Sn	Р
[%]	[%]	[%]	[%]	[%]	[%]
rem	1.4-1.7	0.2-0.35	0.2-0.7	0.02-0.3	0.01-0.03

Composition of this alloy is in accordance with RoHS for electric & electronic components and ELV for the automotive industry.

Physical properties

Melting point	Density	с _р @ 20°С	Young's modulus	Thermal cond.	Electrical cond.		α @20-300°C	
[°C]	[g/cm ³]	[kJ/kgK]	[GPa]	[W/mK]	[MS/m]	[%IACS]	[10 ⁻⁶ /K]	
1062	8.9	0.377	135	250	≥ 27	≥47	16.8	
Nata. The superified and dustinity supplies to the					c specific l	heat canacity	,	

Note: The specified conductivity applies to the soft condition only.

c_p specific heat capacity $\boldsymbol{\alpha}$ coefficient of thermal expansion

Mechanical properties

	Tensile Strength	Yield Strength	Elongation A ₅₀	Hardness HV	Bend ratio 90° [r]		Bend ratio 180° [r]	
	[MPa]	[MPa]	[%]	[-]	GW	BW	GW	BW
R360	360-430	≥275	≥ 8	100-130	0	0	0	0.5
R410	410-470	≥370	≥7	120-140	0	0.5	0.5	1
R460	460-520	≥410	≥ 5	140-160	0.5	1	1	3
R490	490-560	≥435	≥ 4	150-170	1	1.5	2	3.5
R520	520-590	≥460	≥ 3	155-180	1	2	2.5	4
R490S*	490-560	≥410	≥ 10	150-170	0	0	1	1
R520S*	520-590	≥440	≥ 8	155-180	0.5	0	1.5	1.5
R580S*	580-650	≥510	≥7	170-200	0.5	0.5	1.5	2
R620S	620-700	≥560	≥6	180-210	1	1.5	3	5

r = x * t (thickness $t \le 0.5 mm$)

GW bend axis transverse to rolling direction. BW bend axis parallel to rolling

direction.

Fabrication

properties

Cold formability	good
Hot formability	excellent
Soldering	good
Brazing	good
Oxyacetylene welding	good
Gas shielded arc welding	good
Resistance welding	good
Machinability	fair



conductivity	the grain size. A high level of deformation as well as a small grain size decrease the conductivity.
Corrosion	CuNiSi is resistant to: Natural and industrial atmospheres as well as maritime air, drinking and service water, non oxidizing acids, alkaline solutions and neutral saline solutions.
Resistance	CuNiSi is not resistant to: Ammonia, halogenide, cyanide and hydrogen sulfide solutions and atmospheres, oxidizing acids and sea water (especially at high flow rates).

The electrical conductivity dependence chamical composition, the loyal of cold deformation and

Typical uses Automotive, components of electrical engineering, connectors, springs, relays, sockets, clips, leadframes, pins



100 90 80 70 Residual stress [%] 60 50 40 30 20 longitudinal C19005 R580s initial stress 0.5 x R_{p0.2} transverse 10 LMP=(273.15+T) x (20+log10(t)) x 0.001 0 7.5 8.0 8.5 9.0 9.5 10.0 10.5 11.0 Larson Miller Parameter

Stress relaxation data shown as residual stress against Larson Miller Parameter. The Larson Miller Parameter represents temperature and time. Test method: Mandrel test according to ASTM E328.

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